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(12) **United States Design Patent**  
**Wolf et al.**

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- (54) **NASAL MASK**
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- (\*\*) Term: **15 Years**
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**Related U.S. Application Data**

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- (51) **LOC (10) Cl.** ..... **29-02**
- (52) **U.S. Cl.**  
USPC ..... **D24/110.4**
- (58) **Field of Classification Search**  
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D1/122, 126, 127; D25/119, 121, 122,  
D25/124; D8/300, 310, 312, 321, 322,  
D8/374, 378, 400, 402, 499; D3/7-10,  
D3/17  
CPC ..... A61M 16/06; A61M 16/0616; A61M  
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See application file for complete search history.

(56) **References Cited**

**U.S. PATENT DOCUMENTS**

- 1,206,045 A 11/1916 Smith
- 1,740,083 A 12/1929 Galvin
- 2,663,297 A 12/1953 Turnberg
- 3,041,719 A \* 7/1962 Haseltine ..... B21C 37/151  
138/111

- 3,393,677 A 7/1968 Echard
- 3,889,671 A 6/1975 Baker
- 4,248,218 A 2/1981 Fischer
- 4,846,170 A 7/1989 McAnalley et al.
- 4,944,310 A 7/1990 Sullivan
- 5,267,557 A 12/1993 Her-Mou
- D398,987 S 9/1998 Cotner et al.
- D416,622 S \* 11/1999 Selman ..... D24/127  
(Continued)

**FOREIGN PATENT DOCUMENTS**

WO 2012/006415 A1 1/2012

**OTHER PUBLICATIONS**

Introducing the New Silhouette Nasal Mask: It Will Change Your View of Nitrous Oxide. Parker Porter. Date accessed: Mar. 24, 2017. <<http://www.porterinstrument.com/silhouette>>.\*

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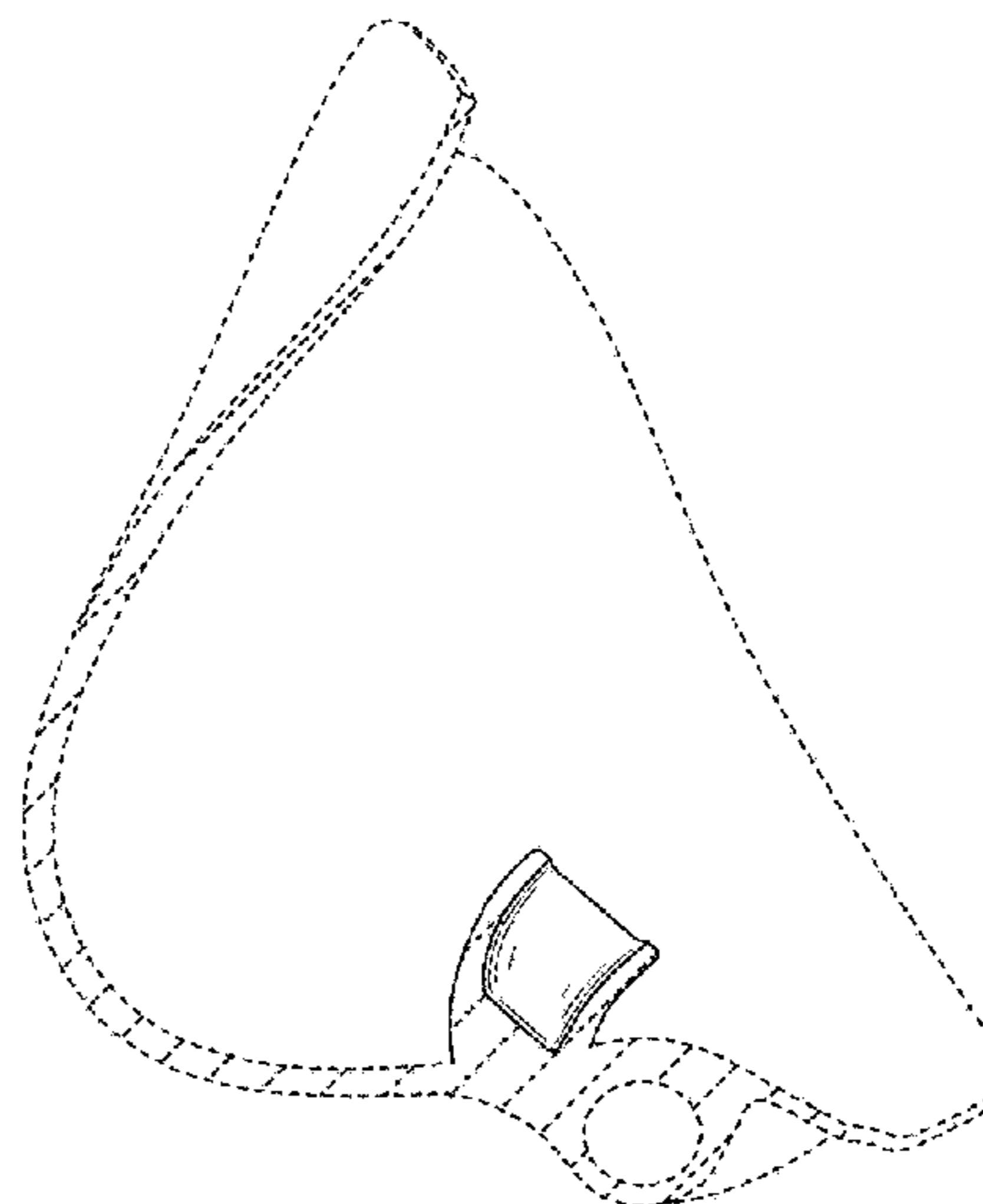
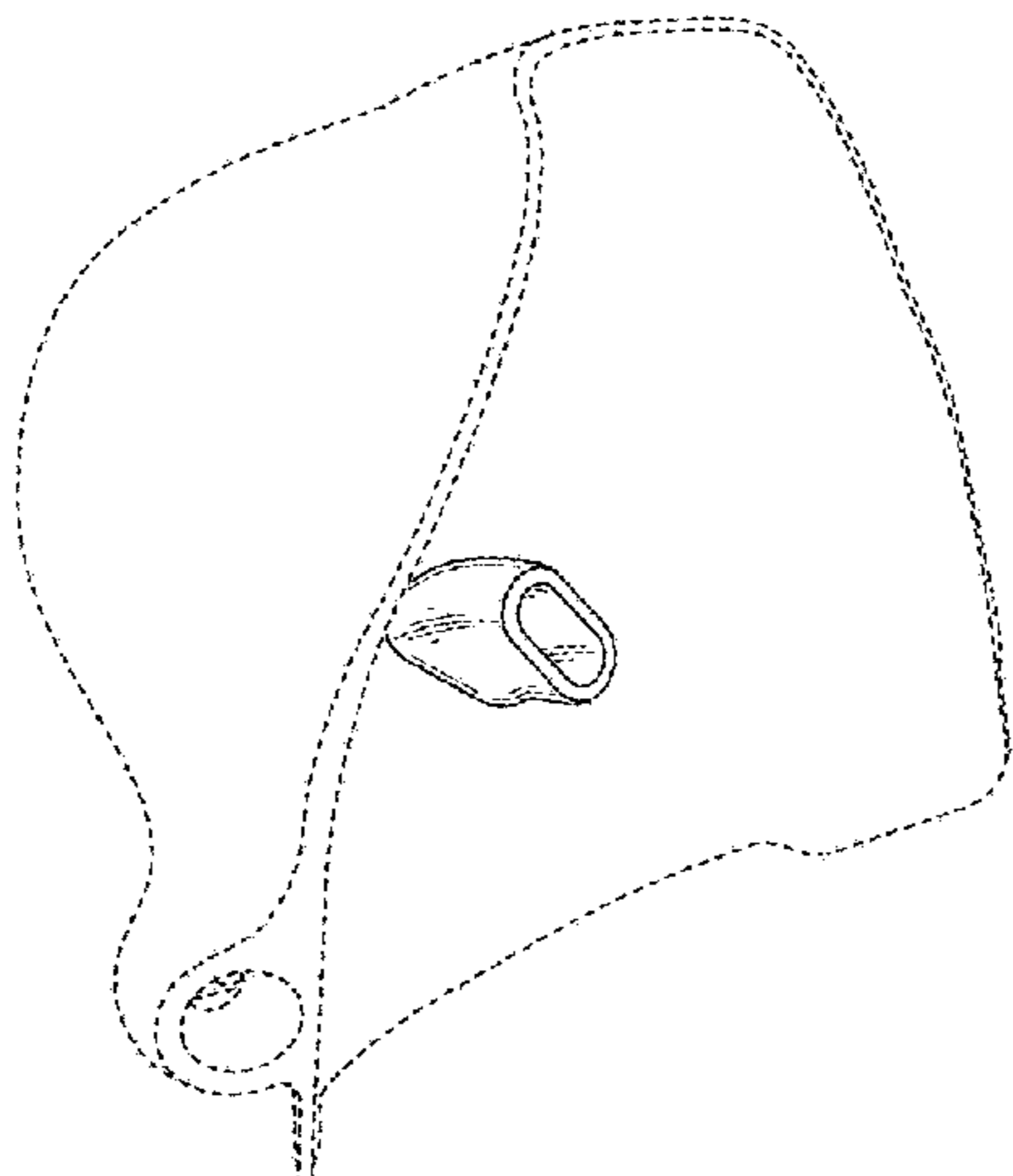
(57) **CLAIM**

The ornamental design for a nasal mask, as shown and described.

**DESCRIPTION**

FIG. 1 is a perspective view of a nasal mask showing our new design;  
 FIG. 2 is a rear view thereof;  
 FIG. 3 is a right side view thereof;  
 FIG. 4 is a cross-sectional view thereof, taken in the direction of line 4-4 of FIG. 3;  
 FIG. 5 is a rear view thereof; and,  
 FIG. 6 is a cross-sectional view thereof, taken in the direction of line 6-6 of FIG. 5.  
 The broken lines in the drawings illustrate portions of the nasal mask that form no part of the claimed design.

**1 Claim, 6 Drawing Sheets**



(56)

**References Cited**

U.S. PATENT DOCUMENTS

6,019,101	A	2/2000	Cotner et al.	
D488,711	S *	4/2004	Heisey .....	D8/374
6,958,691	B1 *	10/2005	Anderson .....	A61B 5/0002 128/200.14
7,255,107	B1 *	8/2007	Gomez .....	A61M 16/0666 128/206.11
D551,340	S *	9/2007	Wood .....	D24/110
8,136,527	B2 *	3/2012	Wondka .....	A61M 16/00 128/200.24
D665,496	S *	8/2012	Lee .....	D24/110.5
8,893,720	B2	11/2014	Cohen	
D747,792	S *	1/2016	Babbage .....	D24/110
D757,929	S *	5/2016	Kerber .....	D24/110.1
D777,905	S *	1/2017	Wolf .....	D24/110.4
2003/0145859	A1	8/2003	Bohn et al.	
2004/0079374	A1	4/2004	Thornton	
2006/0107958	A1 *	5/2006	Sleeper .....	A61M 16/0666 128/206.11
2010/0192957	A1 *	8/2010	Hobson .....	A61M 16/0666 128/207.18
2010/0252037	A1	10/2010	Wondka	
2013/0109992	A1	5/2013	Guyette	
2016/0030696	A1 *	2/2016	Klenner .....	A61M 16/0066 128/207.18

\* cited by examiner

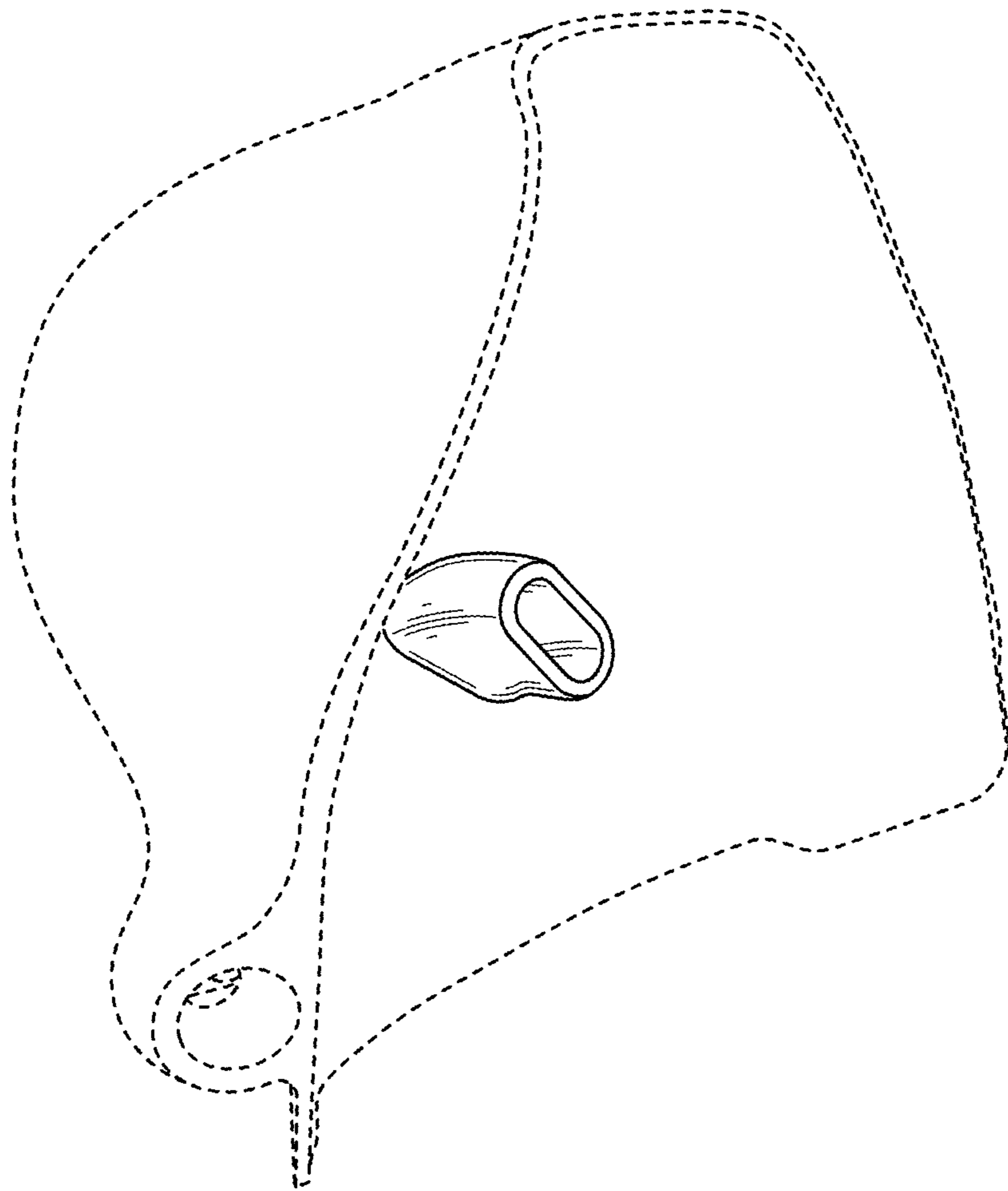


FIG. 1

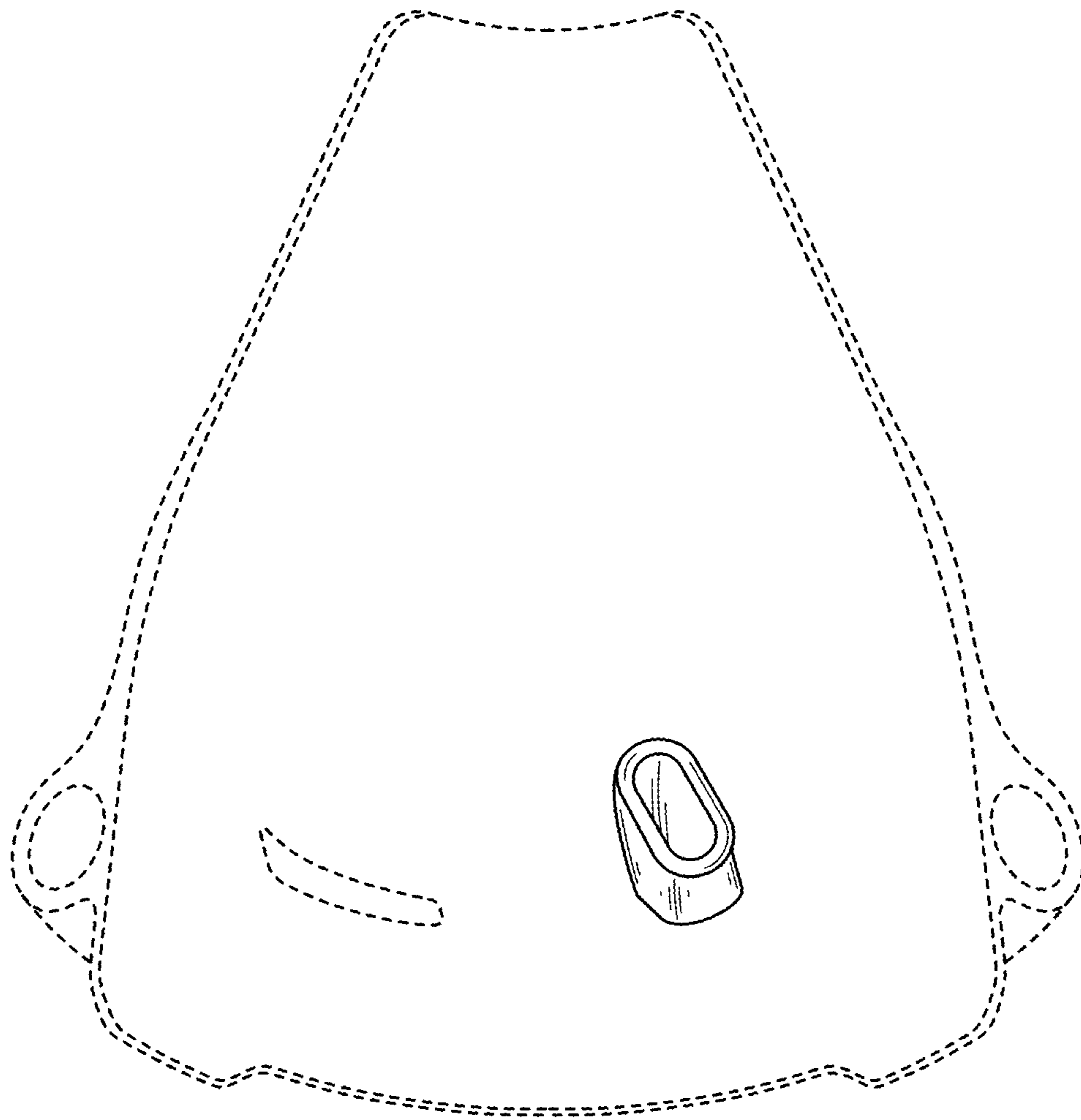


FIG. 2

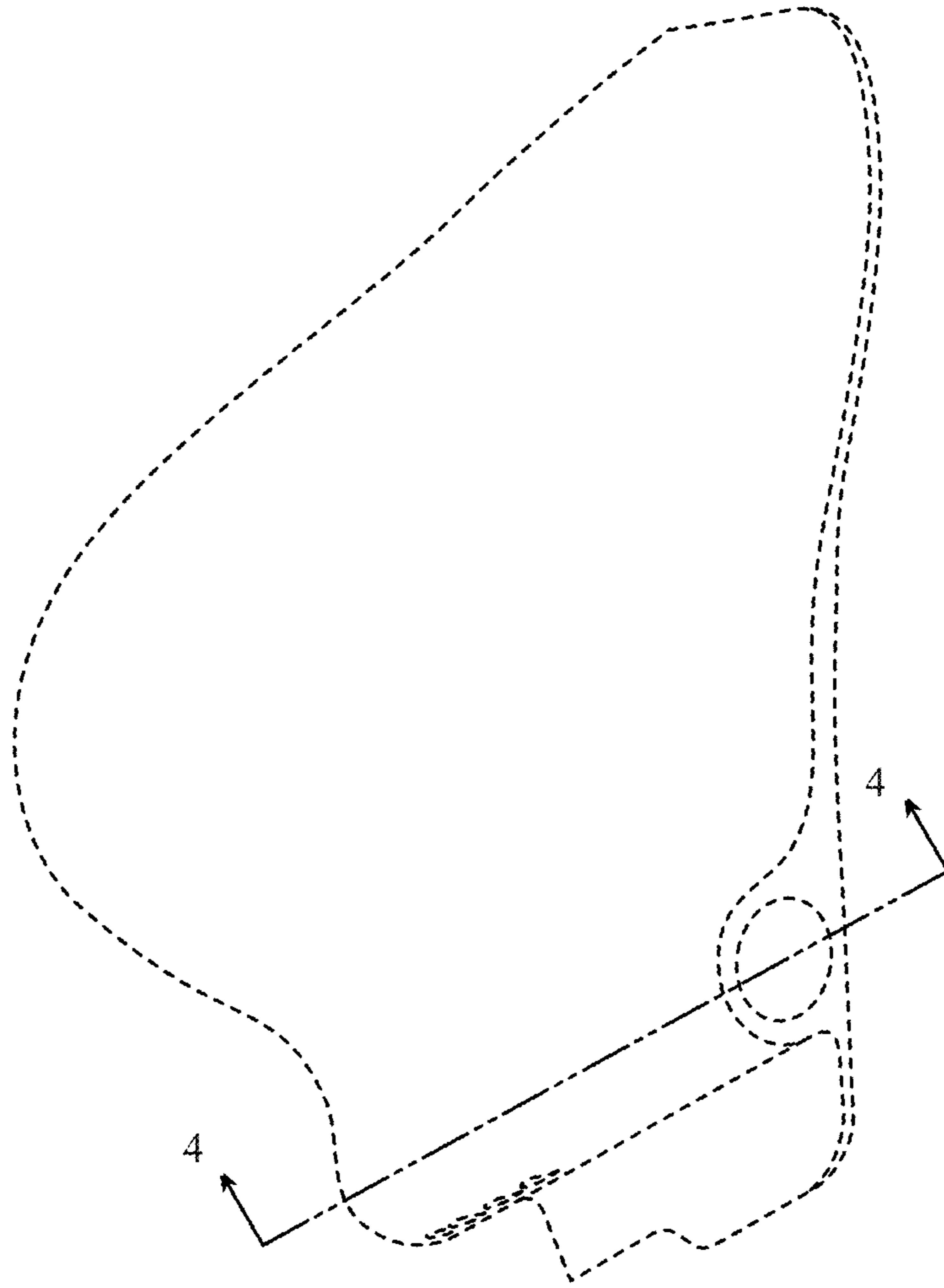


FIG. 3

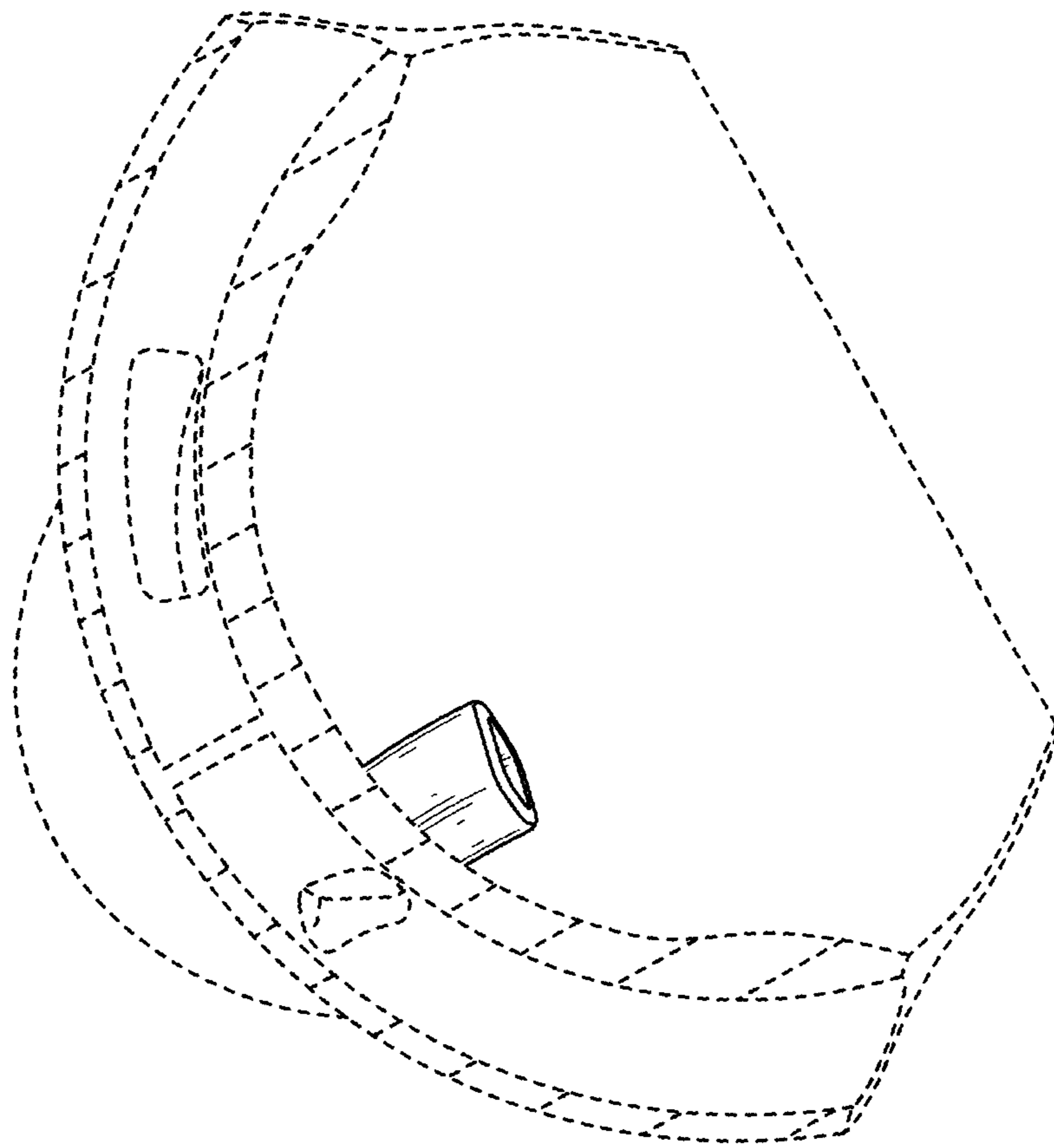


FIG. 4

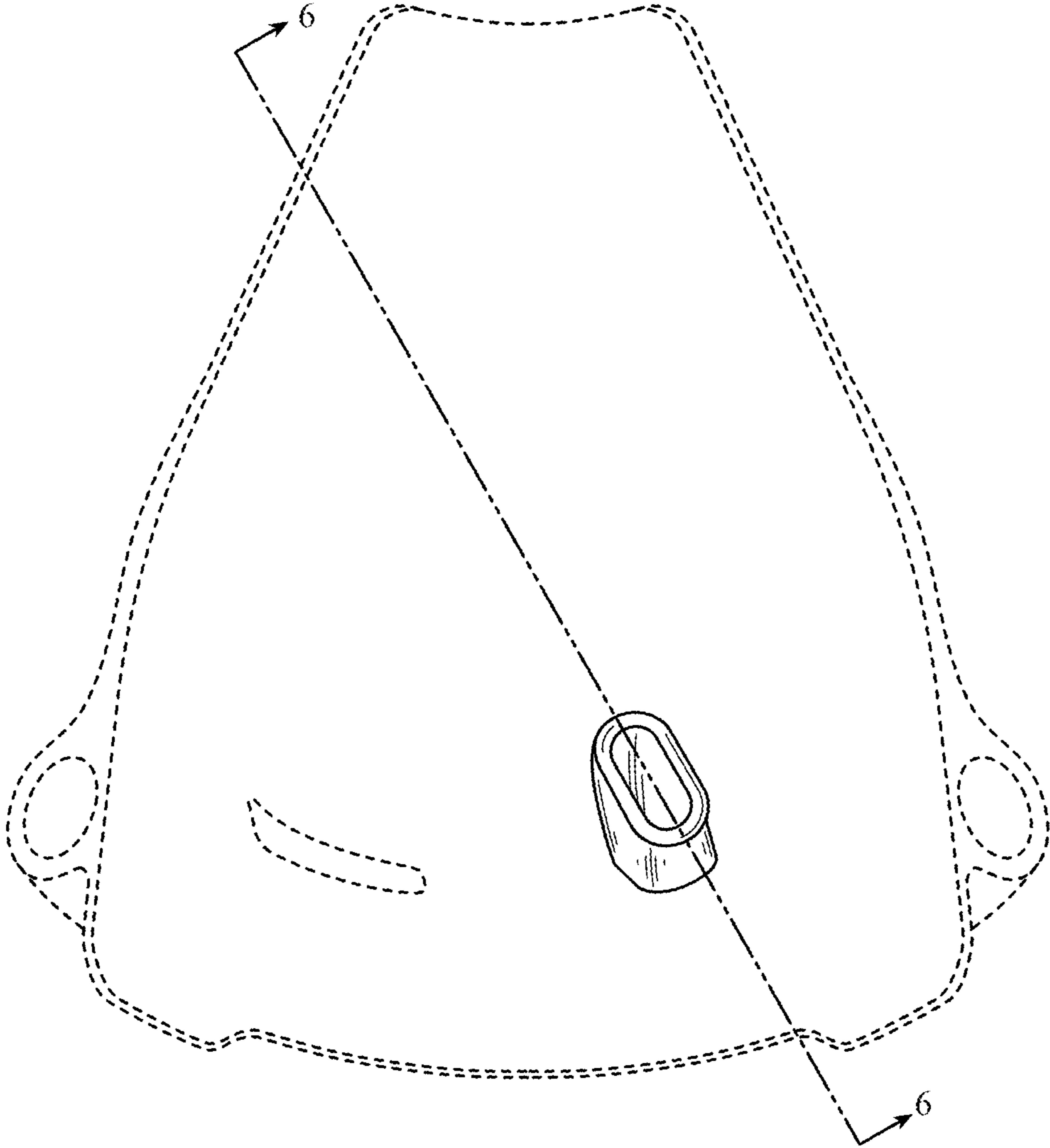


FIG. 5

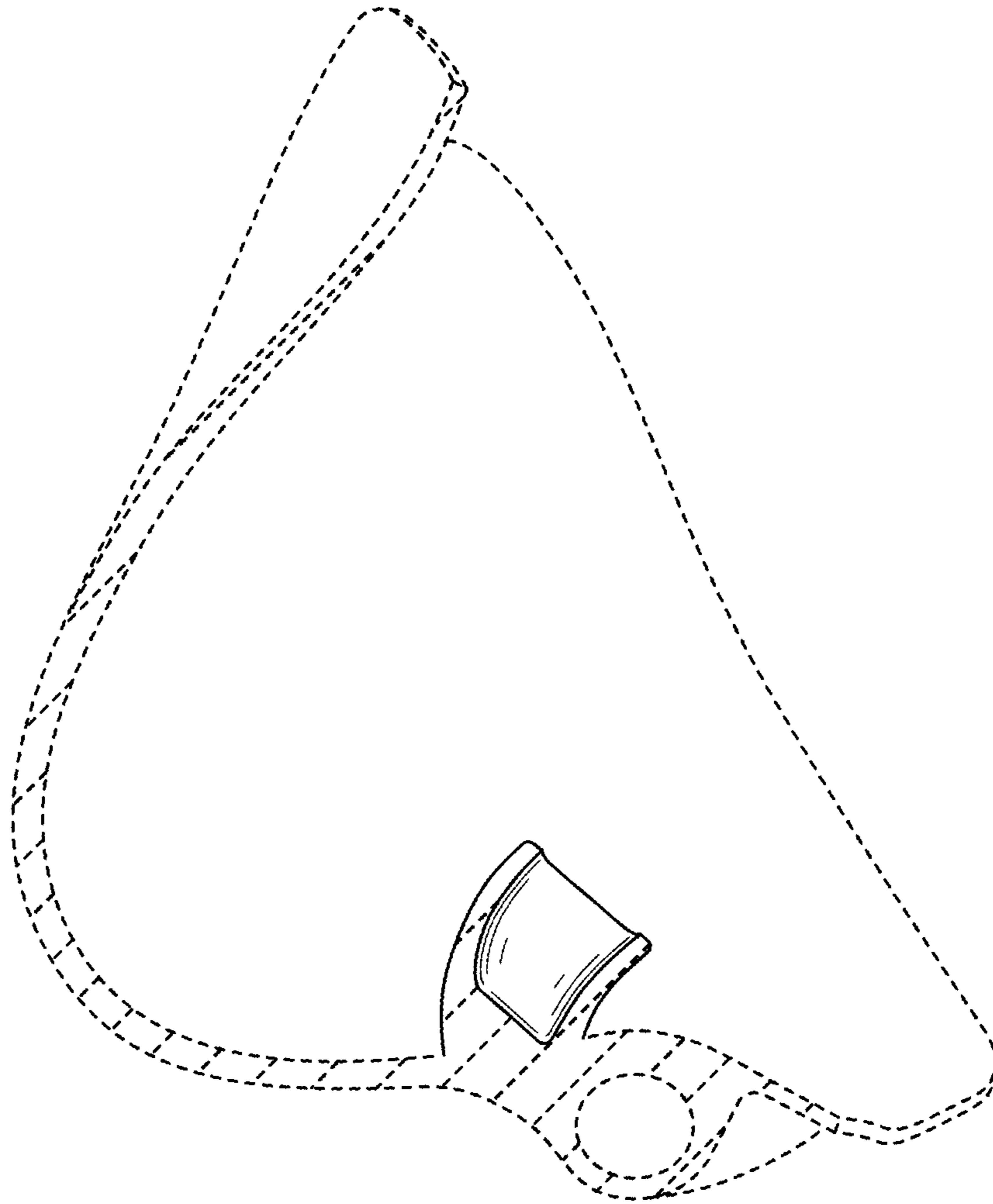


FIG. 6